1. A semiconductor light emitting device comprising: an active layer composed of a nitride based

5 semiconductor;

a cladding layer formed on said active layer, composed of a nitride based semiconductor of a first conductivity type, and having a flat portion and a ridge portion formed on the flat portion; and

a first current blocking layer formed on said flat portion and on sidewalls of said ridge portion of said cladding layer and composed of a high-resistive nitride based semiconductor containing impurities.

2. The semiconductor light emitting device according to claim 1, wherein

said impurities contain at least one of zinc, peryllium, calcium, and carbon.

3. The semiconductor light emitting device according to claim 1, wherein

said first current blocking layer has a resistance value of not less than 1.5  $\Omega\cdot\text{cm}$ .

4. The semiconductor light emitting device according

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to claim 1, further comprising

a second current blocking layer formed on said first current blocking layer and composed of a nitride based semiconductor of a second conductivity type opposite to said first conductivity type.

5. The semiconductor light emitting device according to claim 1, wherein

the thickness of said first current blocking layer is not less than 0.5  $\,\mu\,\mathrm{m}$  .

6. The semiconductor light emitting device according to claim 5, wherein

the thickness of said first current blocking layer is not less than 1.0  $\mu \, \mathrm{m}$ .

7. The semiconductor light emitting device according to claim 1, wherein

the thickness of the flat portion of said cladding 20 layer is not more than 0.3  $\mu$ m.

8. The semiconductor light emitting device according to claim 7, wherein

the thickness of the flat portion of said cladding 25 layer is not more than 0.08  $\mu$ m.

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9. The semiconductor light emitting device according to claim 1, wherein

said hitride based semiconductor contains at least one of boron, gallium, aluminum, indium, and thallium.

10. A semiconductor light emitting device comprising an active layer composed of a nitride based semiconductor;

a cladding layer formed on said active layer, composed of a nitride based semiconductor of a first conductivity type, and having a flat portion and a ridge portion formed on the flat portion,

said cladding layer having a recess on said flat portion along both sidewalls of said ridge portion; and

a first current blocking layer formed on said flat portion and on the sidewalls of said ridge portion such that it is embedded in said recess of said cladding layer.

11. The semiconductor light emitting device according to claim 10, wherein

said first current blocking layer is composed of a high-resistive nitride based semiconductor containing impurities.

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12. The semiconductor light emitting device according to claim 10, wherein

said impurities contain at least one of zinc, beryllium, calcium, and carbon.

13. The semiconductor light emitting device according to claim 10, wherein

said first current blocking layer has a resistance value of not less than 1.5  $\Omega \cdot \text{cm}$ .

14. The semiconductor light emitting device according to claim 10, further comprising

a second current blocking layer formed on said first current blocking layer and composed of a nitride based semiconductor of a second conductivity type opposite to said first conductivity type.

15. The semiconductor light emitting device according to claim 10, wherein

the thickness of said first current blocking layer is not less than 0.5  $\mu\,\mathrm{m}.$ 

16. The semiconductor light emitting device according to claim 15, wherein

the thickness of said first current blocking layer is

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17. The semiconductor light emitting device according to claim 10, wherein

the thickness of the flat portion of said cladding layer is not more than 0.3  $\mu$  m.

18. The semiconductor light emitting device according to claim 17, wherein

the thickness of the flat portion of said cladding layer is not more than 0.08  $\mu\,\mathrm{m}.$ 

19. The semiconductor light emitting device according to claim 10,

of boron, gallium, aluminum, indium, and thallium.

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